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NOTICE OF ALLOWANCE AND FEE(S) DUE

22850

1940 DUKE STREET

7590

09/16/2008

OBLON, SPIVAK, MCCLELLAND MAIER & NEUSTADT, P.C. ALEXANDRIA, VA 22314

EXAMINER CARRILLO, BIBI SHARIDAN ART UNIT

PAPER NUMBER

1792

DATE MAILED: 09/16/2008

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/715,859	11/19/2003	Hiromi Sakima	245742US2	5595

TITLE OF INVENTION: PLASMA PROCESSING METHOD AND APPARATUS

ı	APPLN. TYPE	SMALL ENTITY	ISSUE FEE DUE	PUBLICATION FEE DUE	PREV. PAID ISSUE FEE	TOTAL FEE(S) DUE	DATE DUE
•	nonprovisional	NO	\$1440	\$300	\$0	\$1740	12/16/2008

THE APPLICATION IDENTIFIED ABOVE HAS BEEN EXAMINED AND IS ALLOWED FOR ISSUANCE AS A PATENT. <u>PROSECUTION ON THE MERITS IS CLOSED</u>. THIS NOTICE OF ALLOWANCE IS NOT A GRANT OF PATENT RIGHTS. THIS APPLICATION IS SUBJECT TO WITHDRAWAL FROM ISSUE AT THE INITIATIVE OF THE OFFICE OR UPON PETITION BY THE APPLICANT. SEE 37 CFR 1.313 AND MPEP 1308.

THE ISSUE FEE AND PUBLICATION FEE (IF REQUIRED) MUST BE PAID WITHIN THREE MONTHS FROM THE MAILING DATE OF THIS NOTICE OR THIS APPLICATION SHALL BE REGARDED AS ABANDONED. THIS STATUTORY PERIOD CANNOT BE EXTENDED. SEE 35 U.S.C. 151. THE ISSUE FEE DUE INDICATED ABOVE DOES NOT REFLECT A CREDIT FOR ANY PREVIOUSLY PAID ISSUE FEE IN THIS APPLICATION. IF AN ISSUE FEE HAS PREVIOUSLY BEEN PAID IN THIS APPLICATION (AS SHOWN ABOVE), THE RETURN OF PART B OF THIS FORM WILL BE CONSIDERED A REQUEST TO REAPPLY THE PREVIOUSLY PAID ISSUE FEE TOWARD THE ISSUE FEE NOW DUE.

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B. If applicant claimed SMALL ENTITY status before, or is now claiming SMALL ENTITY status, check box 5a on Part B - Fee(s) Transmittal and pay the PUBLICATION FEE (if required) and 1/2 the ISSUE FEE shown above.

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III. All communications regarding this application must give the application number. Please direct all communications prior to issuance to Mail Stop ISSUE FEE unless advised to the contrary.

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Complete and send this form, together with applicable fee(s), to: Mail Mail Stop ISSUE FEE

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INSTRUCTIONS: This form should be used for transmitting the ISSUE FEE and PUBLICATION FEE (if required). Blocks 1 through 5 should be completed where appropriate. All further correspondence including the Patent, advance orders and notification of maintenance fees will be mailed to the current correspondence address as indicated unless corrected below or directed otherwise in Block 1, by (a) specifying a new correspondence address; and/or (b) indicating a separate "FEE ADDRESS" for maintenance fee notifications.

Note: A certificate of mailing can only be used for domestic mailings of the CURRENT CORRESPONDENCE ADDRESS (Note: Use Block 1 for any change of address) Fee(s) Transmittal. This certificate cannot be used for any other accompanying papers. Each additional paper, such as an assignment or formal drawing, must have its own certificate of mailing or transmission. 22850 09/16/2008 Certificate of Mailing or Transmission OBLON, SPIVAK, MCCLELLAND MAIER & NEUSTADT, P.C.I hereby certify that this Fee(s) Transmittal is being deposited with the United States Postal Service with sufficient postage for first class mail in an envelope addressed to the Mail Stop ISSUE FEE address above, or being facsimile transmitted to the USPTO (571) 273-2885, on the date indicated below. 1940 DUKE STREET ALEXANDRIA, VA 22314 (Depositor's name (Signature (Date APPLICATION NO. FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. FILING DATE 10/715,859 11/19/2003 Hiromi Sakima 245742US2 5595 TITLE OF INVENTION: PLASMA PROCESSING METHOD AND APPARATUS APPLN. TYPE SMALL ENTITY ISSUE FEE DUE PUBLICATION FEE DUE PREV. PAID ISSUE FEE TOTAL FEE(S) DUE DATE DUE nonprovisional NO \$1440 \$300 \$0 \$1740 12/16/2008 **EXAMINER** ART UNIT CLASS-SUBCLASS CARRILLO, BIBI SHARIDAN 1792 134-001100 1. Change of correspondence address or indication of "Fee Address" (37 CFR 1.363). 2. For printing on the patent front page, list (1) the names of up to 3 registered patent attorneys ☐ Change of correspondence address (or Change of Correspondence Address form PTO/SB/122) attached. or agents OR, alternatively, (2) the name of a single firm (having as a member a ☐ "Fee Address" indication (or "Fee Address" Indication form PTO/SB/47; Rev 03-02 or more recent) attached. Use of a Customer Number is required. registered attorney or agent) and the names of up to 2 registered patent attorneys or agents. If no name is listed, no name will be printed. 3. ASSIGNEE NAME AND RESIDENCE DATA TO BE PRINTED ON THE PATENT (print or type) PLEASE NOTE: Unless an assignee is identified below, no assignee data will appear on the patent. If an assignee is identified below, the document has been filed for recordation as set forth in 37 CFR 3.11. Completion of this form is NOT a substitute for filing an assignment. (A) NAME OF ASSIGNEE (B) RESIDENCE: (CITY and STATE OR COUNTRY) 4b. Payment of Fee(s): (Please first reapply any previously paid issue fee shown above) 4a. The following fee(s) are submitted: lssue Fee A check is enclosed. Publication Fee (No small entity discount permitted) Payment by credit card. Form PTO-2038 is attached. The Director is hereby authorized to charge the required fee(s), any deficiency, or credit any overpayment, to Deposit Account Number ______ (enclose an extra copy of this fo Advance Order - # of Copies _ (enclose an extra copy of this form). 5. Change in Entity Status (from status indicated above) a. Applicant claims SMALL ENTITY status. See 37 CFR 1.27. ■ b. Applicant is no longer claiming SMALL ENTITY status. See 37 CFR 1.27(g)(2). NOTE: The Issue Fee and Publication Fee (if required) will not be accepted from anyone other than the applicant; a registered attorney or agent; or the assignee or other party in interest as shown by the records of the United States Patent and Trademark Office. Authorized Signature Date Typed or printed name Registration No. This collection of information is required by 37 CFR 1.311. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 12 minutes to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, Virginia 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450.

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10/715,859	11/19/2003	Hiromi Sakima	245742US2	5595	
22850 75	90 09/16/2008	09/16/2008		EXAMINER	
OBLON, SPIVA	K, MCCLELLAND	CARRILLO, BIBI SHARIDAN			
1940 DUKE STREET			ART UNIT	PAPER NUMBER	
ALEXANDRIA, V	A 22314		1792		
			DATE MAILED: 09/16/200	8	

Determination of Patent Term Adjustment under 35 U.S.C. 154 (b)

(application filed on or after May 29, 2000)

The Patent Term Adjustment to date is 682 day(s). If the issue fee is paid on the date that is three months after the mailing date of this notice and the patent issues on the Tuesday before the date that is 28 weeks (six and a half months) after the mailing date of this notice, the Patent Term Adjustment will be 682 day(s).

If a Continued Prosecution Application (CPA) was filed in the above-identified application, the filing date that determines Patent Term Adjustment is the filing date of the most recent CPA.

Applicant will be able to obtain more detailed information by accessing the Patent Application Information Retrieval (PAIR) WEB site (http://pair.uspto.gov).

Any questions regarding the Patent Term Extension or Adjustment determination should be directed to the Office of Patent Legal Administration at (571)-272-7702. Questions relating to issue and publication fee payments should be directed to the Customer Service Center of the Office of Patent Publication at 1-(888)-786-0101 or (571)-272-4200.

	Application No.	Applicant(s)				
	10/715,859	SAKIMA, HIROMI				
Notice of Allowability	Examiner	Art Unit				
	Sharidan Carrilla	1702				
	Sharidan Carrillo	1792				
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED or other appropriate complete. This application is	in this application. If not included nunication will be mailed in due course. TI	HIS itiative			
1. This communication is responsive to 6/12/08.						
2. The allowed claim(s) is/are <u>1-11 and 20-28</u> .						
3. ☑ Acknowledgment is made of a claim for foreign priority u a) ☑ All b) ☐ Some* c) ☐ None of the: 1. ☑ Certified copies of the priority documents have	e been received.	, ,,				
2. Certified copies of the priority documents have	• •					
3. Copies of the certified copies of the priority do	ocuments have been receiv	ed in this national stage application from t	:he			
International Bureau (PCT Rule 17.2(a)).						
* Certified copies not received:						
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		ile a reply complying with the requirements	6			
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which giv			F			
5. CORRECTED DRAWINGS (as "replacement sheets") mu	st be submitted.					
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached						
1) ☐ hereto or 2) ☐ to Paper No./Mail Date	1) hereto or 2) to Paper No./Mail Date					
(b) ☐ including changes required by the attached Examiner Paper No./Mail Date	(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date					
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in						
6. DEPOSIT OF and/or INFORMATION about the depo- attached Examiner's comment regarding REQUIREMENT						
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. ☐ Notice of	Informal Patent Application				
2. \square Notice of Draftperson's Patent Drawing Review (PTO-948)		Summary (PTO-413),				
3. Information Disclosure Statements (PTO/SB/08),	Paper N 7. ⊠ Examiner	o./Mail Date 's Amendment/Comment				
Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner	's Statement of Reasons for Allowance				
of Biological Material	9.	<u>_</u> .				
/Sharidan Carrillo/						
Primary Examiner, Art Unit 1792						

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EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Mr. Lee Stepina on 9/3/08

The application has been amended as follows:

Replace all previous versions of claims 1, 6, 21, 24, 25, and 28 with the following:

Claim 1 (Currently Amended): A plasma processing method having a first and a second plasma processing step carried out in a single chamber, wherein deposits are substantially accumulated in the chamber during the first plasma processing step, the method comprising the steps of:

dry cleaning an inside of the chamber by using a dummy substrate between the first and the second plasma processing steps,

wherein the dry cleaning step is performed by supplying into the chamber a deposit removing gas for removing the deposits produced in the chamber during the first plasma processing step and supplying a dummy substrate etching gas that etches the dummy substrate and stabilizes an etching rate of the second plasma processing step, which is carried out right after the dry cleaning step,

wherein the second plasma processing step includes a plasma etching performed without producing deposits in the chamber, and

wherein a first CF-based gas is supplied in the first plasma processing step, and a second CF-based gas comprising CF₄, O₂, and Ar is supplied in the second plasma processing step, and the first CF-based gas has a different composition from the second CF-based gas such that a fluorine/carbon (F/C) ratio of the first CF-based gas is smaller than that of the second CF-based gas.

Claim 6 (Currently Amended): A plasma processing method comprising the sequential steps of:

performing a first plasma etching step in a chamber, during which deposits are produced and accumulated in the chamber;

dry cleaning an inside of the chamber by using a dummy substrate; and performing a second plasma etching step without producing deposits in the chamber, wherein the dry cleaning step is performed by supplying into the chamber a deposit removing gas for removing the deposits and a dummy substrate etching gas that etches the dummy substrate and stabilizes an etching rate of the second plasma etching step carried out right after the dry cleaning step,

wherein a ratio of a flow rate of the dummy substrate etching gas to that of the deposit removing gas is not less than about 0.14% but not larger than about 7.1%, and

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wherein a first CF-based gas is used in the first plasma etching step, and a second CF-based gas comprising CF_4 , O_2 , and Ar is used in the second plasma etching step, and the first CF-based gas has a different composition from the second CF-based gas such that a fluorine/carbon (F/C) ratio of the first CF-based gas is smaller than that of the second CF-based gas.

Claim 21 (Currently Amended): The plasma processing method of Claim 1, wherein the supplying the first CF-based gas includes supplying C₄F₈,

wherein the supplying the deposit removing gas and supplying the dummy substrate etching gas in the dry cleaning step includes supplying 0_2 and CF_4 , respectively.

Claim 24 (Currently Amended): The plasma processing method of Claim 1,

wherein the first and the second plasma processing steps and the dry cleaning step are carried out without a seasoning step occurring between the dry cleaning and the second plasma processing step.

Claim 25 (Currently Amended): The plasma processing method of Claim 6, wherein the supplying the first CF-based gas includes supplying C₄F₈,

wherein the supplying the deposit removing gas and supplying the dummy substrate etching gas in the dry cleaning step includes supplying 0_2 and CF_4 , respectively.

Claim 28 (Currently Amended): The plasma processing method of Claim 6,

wherein the first and the second plasma etching steps and the dry cleaning step are carried out without a seasoning step occurring between the dry cleaning and the second plasma processing step.

Claim 26: lines 2 and 6, delete "processing" and insert -etching-

2. The following is an examiner's statement of reasons for allowance: The prior art fails to teach a first etching step, followed by a drying cleaning step, followed by a second etching step using a CF based gas comprising CF4, O2, and Argon, wherein the first CF based gas used in the first etching step has a different composition than the second-CF based gas used in the second etching step, such that a fluorine/carbon ratio of the first CF-based gas is smaller than that of the second CF based gas. The closest prior art is that of Van Autryve et al. and Chen et al. Van Autryve et al. teach a first etch step using a halogenated gas in combination with a passivating gas, such as CHF3. Van Autryve et al. teach a dry cleaning step and a second etching step using the passivating gas CHF3 gas. Chen teaches the same etching gas for both the first and second etches, with a dry-cleaning step in between. In Summary, neither reference teaches a first CF based gas used in the first etching step, which as a different composition that the second CF-based gas, wherein the second CF based gas

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comprises CF4, oxygen, argon, and wherein a fluorine/carbon ratio of the first CF based gas is smaller than that of the second CF based gas. The additional changes to the amendments were made to correct minor 112, second paragraph issues in order to place the application in better condition for allowance.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sharidan Carrillo whose telephone number is 571-272-1297. The examiner can normally be reached on M-W, F 6:30-5:00pm, alternating Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Barr can be reached on 571-272-1414. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Sharidan Carrillo/ Primary Examiner, Art Unit 1792

bsc